

Abstract Submitted
for the MAR07 Meeting of
The American Physical Society

Micro- and nanomachined tools for measuring in-plane thermal conductivity of thermoelectric thin films R. RAHMAN, R. SULTAN, F. BASET, B. L. ZINK, University of Denver — Many of the potential next-generation thermoelectric materials being studied are either thin films or nanostructures that are expected to have anisotropic properties. For example, the thermal conductivity of a layered thin film in the plane of the film, k_{\parallel} , is likely to be different from that perpendicular to the layers, k_{\perp} . Techniques such as the 3ω method and picosecond thermoreflectance allow accurate measurements of k_{\perp} at temperatures relevant to thermoelectrics, but measuring k_{\parallel} is often difficult. In this talk we discuss our efforts to design and demonstrate accurate measurements of k_{\parallel} of thin films from 77–475 K using micro- and nanomachined thermal isolation platforms. Using thin-film structures to support the thin-film sample reduces background contributions, and careful control of the geometry keeps radiation errors small. We will also discuss plans for a next-generation device that will simultaneously measure thermal conductivity, thermopower, and electrical conductivity of a thin-film or nanostructure, allowing determination of the thermoelectric figure-of-merit, ZT .

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Date submitted: 20 Nov 2006

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